

**INFORMATION DISCLOSURE
STATEMENT BY APPLICANT**

(Use as many sheets as necessary)

Complete if Known

Application Number	10/821,825
Filing Date	April 8, 2004
First Named Inventor	Ralf BAUMANN
Art Unit	2193
Examiner Name	Chih-Ching CHOW
Attorney Docket Number	07781.0158-00

Sheet	1	of	1
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U.S. PATENTS AND PUBLISHED U.S. PATENT APPLICATIONS

Examiner Initials	Cite No. ¹	Document Number	Issue or Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear
		Number-Kind Code ² (if known)			
/C.C./		US-2003/0145282	07-31-2003	Thomas	
/C.C./		US-2005/0005168	01-06-2005	Dick	
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/C.C./		US-5,826,025	10-20-1998	Gramlich	
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/C.C./		US-7,146,565	12-05-2006	Toyama	
/C.C./		US-7,194,679	03-20-2007	Green	

Note: Submission of copies of U.S. Patents and published U.S. Patent Applications is not required.**FOREIGN PATENT DOCUMENTS**

Examiner Initials	Cite No. ¹	Foreign Patent Document	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear	Translation ⁵
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NONPATENT LITERATURE DOCUMENTS

Examiner Initials	Cite No. ¹	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.	Translation ⁶

Examiner Signature	/Chih Ching Chow/	Date Considered	11/10/08
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